

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	71	(laser) near3 (ablation or ablating) same (power near density or fluence) same (pulse or ns!) same (metal or aluminum or al or copper or cu)	US-PGPUB; USPAT; JPO	OR	ON	2005/08/12 09:39
L2	354	(laser) near3 (ablation or ablating) same (power near density or fluence) same (pulse or ns!)	US-PGPUB; USPAT; JPO	OR	ON	2005/08/12 09:38
L1	17	(US-20020058420-\$ or US-20020187594-\$ or US-20020196401-\$ or US-20030080089-\$ or US-20030134506-\$ or US-20030178399-\$ or US-20030186078-\$ or US-20040149986-\$ or US-20050007645-\$).did. or (US-5514618-\$ or US-6146715-\$ or US-6376799-\$ or US-6433489-\$ or US-6576867-\$ or US-6719916-\$).did. or (JP-08222371-\$ or JP-2004140003-\$).did.	US-PGPUB; USPAT; JPO	OR	ON	2005/08/12 09:37
S51	129	438/669.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 17:08
S50	85	438/666.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 17:08
S49	13	438/609.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:57
S48	22	438/608.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:56
S47	28	438/35.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:53
S46	62	438/34.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:50
S45	92	(laser or light or beam) near5 (etching or etched or etch or ablating or ablation or ablated or ablate) same (optical or light or beam or laser) near3 (expander or expansion or expanding or expanded or expand or elongate or elongated) and (light near emitt\$3 or led or oled or oel or electroluminescent or luminescent or light near emiss\$3 or o-led)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:36
S6	308	(laser or light or beam) near5 (etching or etched or etch or ablating or ablation or ablated or ablate) same (optical or light or beam or laser) near3 (expander or expansion or expanding or expanded or expand or elongate or elongated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:17
S44	144	(metal or cathode or anode or ito or electrode) near5 laser near4 (ablation or ablating or ablated or ablate or photoetch\$3 or photo-etch\$3 or laser near2 etch\$3) and laser near10 (pulse) near2 (width or duration)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:16

S40	59	(metal or cathode or anode or ito or electrode) near5 laser near4 (ablation or ablating or ablated or ablate or photoetch\$3 or photo-etch\$3 or laser near2 etch\$3) and laser near10 (ns!)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:15
S43	85	laser near2 (patterning or patterned or structuring or etching or etched or ablation or ablating or ablative or ablated) and (arc or coating or arl or coated) near5 graphite and (krf or excimer or ultraviolet or uv)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:04
S31	78	laser near2 (patterning or patterned or structuring or etching or etched or ablation or ablating or ablative or ablated) and (arc or coating or arl or coated) near5 graphite and (krf or excimer or ultraviolet or uv)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 16:04
S42	233	(absorbing or absorption or antireflective or arl or arc or antireflection or anti-reflective or anti-reflection or absorptive or absorbant) near10 (graphite) near10 (laser or krf or excimer or ablation or ablating)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 15:48
S28	213	(absorbing or absorption or antireflective or arl or arc or antireflection or anti-reflective or anti-reflection or absorptive or absorbant) near10 (graphite) near10 (laser or krf or excimer or ablation or ablating)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 15:48
S41	6	("4413020"   "5057184"   "5460687"   "6037270"   "6177358"   "6627846").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/08/10 15:39
S39	388	(metal or cathode or anode or ito or electrode) near5 laser near4 (ablation or ablating or ablated or ablate or photoetch\$3 or photo-etch\$3 or laser near2 etch\$3) and laser near4 (ns or pulse or width or duration)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 14:38
S38	191	(electrode or ito ro anode or cathode) near8 ("2d" or "1d" or two adj dimensional or two adj dimension or one adj dimensional or one adj dimension or line) near3 (ablation or ablating or ablate or ablated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 14:35
S8	174	(electrode or ito ro anode or cathode) near8 ("2d" or "1d" or two adj dimensional or two adj dimension or one adj dimensional or one adj dimension or line) near3 (ablation or ablating or ablate or ablated)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 14:06
S37	163	(cathode or anode or electrode) near3 (periodic or grating or striped or stripe or strip or bar) same (laser or light or beam) near5 (etching or etched or etch or ablating or ablation or ablated or ablate)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 10:54
S5	157	(cathode or anode or electrode) near3 (periodic or grating or striped or stripe or strip or bar) same (laser or light or beam) near5 (etching or etched or etch or ablating or ablation or ablated or ablate)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 10:54
S36	50	(oled or o-led or organic near light near2 diode) and (electrode or ito or anode or cathode) near7 (ablation or ablated or ablating or ablate)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 09:05
S1	41	(oled or o-led or organic near light near2 diode) and (electrode or ito or anode or cathode) near7 (ablation or ablated or ablating or ablate)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/10 09:04